

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Application of:)
Tadashi MITSUI) Group Art Unit: 2624
Application No.: 10/807,187) Examiner: David RASHID
Filed: March 24, 2004) Confirmation No.: 3737
For: PATTERN MEASURING APPARATUS, PATTERN MEASURING METHOD, AND MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE))))

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

<u>AMENDMENT</u>

In reply to the Office Action mailed January 17, 2008, the period for response having been extended to July 17, 2008, by a Petition for Extension of Time of three months and fee payment filed concurrently herewith, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks follow the amendment section of this paper.

97/18/2008 RMEBRAHT 00000042 060916 10807187

300.00 DA

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